



1762

PATENT: 06150 USA

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLI-
CATION OF : O'Neill, et al

SERIAL NO. : 09/863,150 : GRP. ART UNIT: 1762

FILED : 05/23/2001 : EXAMINER:

FOR : Low Dielectric Constant Material and Method of Processing By CVD

Assistant Commissioner for Patents
Washington, D.C. 20231

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Sir:

TRANSMITTAL OF INFORMATION DISCLOSURE STATEMENT
UNDER 37 C.F.R. 1.97(b)

The Information Disclosure Statement submitted herewith is being filed within three months of the filing date of a national application other than a continued prosecution application under § 1.53(d); within three months of date of entry into the national stage as set forth in § 1.491 in an international application; before the mailing date of a first Office action on the merits; or before the mailing of a first Office action after the filing of a request for continued examination under § 1.114.

The cited reference, U.S. Patent No. 6,410,463, discloses at Example 2 a film having a dielectric constant of 2.49 formed from a mixture of DMDMOS, SiF₄ and He, however, no oxygen-providing gas (e.g., O₂) is used in the production of the film, or any other film of the Examples.

Respectfully submitted,

Geoffrey L. Chase
Geoffrey L. Chase
Attorney for Applicant(s)
Registration No. 28,059

RECEIVED

SEP 20 2002

TC 1700

7201 Hamilton Boulevard
Allentown, PA 18195-1501
(610) 481-7265